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37. (Twice Amended) The method of fabricating ceramics as defined in claim 25, wherein the first ceramic film is formed by a coating method, the liquid source misted chemical deposition (LSMCD), the chemical vapor deposition (CVD), or a sputtering method.

C3  
39. (Twice Amended) The method of fabricating ceramics as defined in claim 23, wherein the ceramic film or the second ceramic film is formed of ferroelectrics.

40. (Twice Amended) The method of fabricating ceramics as defined in claim 23, wherein the ceramic film or the second ceramic film is formed at a temperature of less than 600°C.

#### REMARKS

Claims 11-40 and 52-56 are pending. By this Amendment, claims 35, 37, 39 and 40 are amended and claims 41-49 are canceled without prejudice to or disclaimer of the subject matter contained therein. As such, Applicant asserts that the Restriction Requirement has been rendered moot by the cancellation of claims 41-49. It is respectfully requested that the Requirement be withdrawn. Reconsideration in view of the above-outlined amendments and the following remarks is respectfully requested.

The attached Appendix includes a marked-up copy of each rewritten claim (37 C.F.R. §1.121(c)(1)(ii)).

With regard to the Election of Species Requirement, it is respectfully submitted that the subject matter of all species is sufficiently related that a thorough search for the subject matter of the elected species would encompass a search for the subject matter of the remaining species. Thus, it is respectfully submitted that the search and examination of the entire application could be made without serious burden. See MPEP §803 in which it is stated that "if the search and examination of the entire application could be made without serious burden, the Examiner must examine it on the merits, even though it includes claims to distinct or independent inventions" (emphasis added). It is respectfully submitted that this

policy should apply in the present application in order to avoid unnecessary delay and expense to Applicant and duplicative examination by the U.S. Patent and Trademark Office.

The Examiner is respectfully requested to reconsider and withdraw the Election of Species Requirement and to examine all claims in this application.

Claims 35-40 were objected to due to their dependency. By this Amendment, the dependency of claims 35-40 has been corrected. It is respectfully requested the objection be withdrawn.

In view of the foregoing, Applicant submits that this application is in condition for allowance. Favorable reconsideration and prompt allowance of the claims are earnestly solicited.

Should the Examiner believe that anything further is desired in order to place this application in better condition for allowance, the Examiner is invited to contact Applicant's undersigned representative at the telephone number set forth below.

Respectfully submitted,



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Attachment:  
Appendix

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## APPENDIX

## Changes to Claims:

Claims 41-49 are cancelled.

The following is a marked-up version of the amended claims:

35. (Twice Amended) The method of fabricating ceramics as defined in claim ~~1~~23, wherein at least one of the active species and the electromagnetic wave is fed to part of a substrate.

37. (Twice Amended) The method of fabricating ceramics as defined in claim ~~3~~25, wherein the first ceramic film is formed by a coating method, the liquid source misted chemical deposition (LSMCD), the chemical vapor deposition (CVD), or a sputtering method.

39. (Twice Amended) The method of fabricating ceramics as defined in claim ~~1~~23, wherein the ceramic film or the second ceramic film is formed of ferroelectrics.

40. (Amended) The method of fabricating ceramics as defined in claim ~~1~~23, wherein the ceramic film or the second ceramic film is formed at a temperature of less than 600°C.